Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	- 406	716/14.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/17 12:15
S18 3	527	716/13.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/17 11:51
S18 2	28	716/12.ccls. and layer and (filler dummy spacer) same cell	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR .	ON	2006/02/17 11:50
S18 1	898	716/12.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/17 11:28
S17 9	281	716/9.ccls. and (filler spacer dummy feed-through through) and cell	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/17 11:19
S18 0	35	716/9.ccls. and (filler spacer dummy feed-through) and cell	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/17 11:04
S17 8	35	716/9.ccls. and (filler spacer dummy) and cell	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/17 11:03
S17 7	445	716/9.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/17 11:01

						
S17 6	1511	716/10-11.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 21:50
S17 4	109	metal same layer same power same wir\$3 and (toshiba ricoh) and (interconnect\$3 connect\$3 intra adj 2connect\$3) and (power ground) near4 (line wir\$3 rail) and signal	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 21:47
S17 3	167	metal same layer same power same wir\$3 and (toshiba ricoh) and (interconnect\$3 connect\$3 intra adj 2connect\$3) and (power ground) near4 (line wir\$3 rail)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 21:31
S17 1	18	metal same layer same power same wir\$3 and ricoh	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 21:29
S17 0	8	((through filler) adj3 cell spacer) and structur\$2 and metal and multi adj2 layer and (ground power) near4 (rail wir\$3 line) and (interconnect\$3 connect\$3) and signal and region and "716"/\$.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 20:56
S16 9	205	((through filler) adj3 cell spacer) and structur\$2 and metal and multi adj2 layer and (ground power) near4 (rail wir\$3) and (interconnect\$3 connect\$3) and signal and region	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR .	ON	2006/02/16 20:30
S16 8	205	((through filler) adj3 cell spacer) and structure and metal and multi adj2 layer and (ground power) near4 (rail wir\$3) and (interconnect\$3 connect\$3) and signal and region	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 20:30
S16 7	7	((through filler) adj3 cell spacer) and structure and metal and multi adj2 layer and (ground power) near4 (rail wir\$3) and (interconnect\$3 connect\$3) and signal and region and 716/1-18.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 20:29

S16 6	32	((through filler) adj3 cell) and structure and metal and layer and (ground power) near4 (rail wir\$3) and (interconnect\$3 connect\$3) and signal and region and 716/1-18.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 20:26
S16 5	187	((through filler) adj3 cell) and structure and metal and layer and (ground power) near4 (rail wir\$3) and interconnect\$3 and signal and region	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 20:10
S16 3	293	((through filler) adj3 cell) and structure and metal and layer and (ground power) near4 (rail wir\$3) and interconnect\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 20:09
S16 1	3	filler adj cell same structure and metal and layer and (ground power) near4 (rail wir\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 20:07
S16 0	2	filler adj cell same structure and metal and layer and (ground power) adj (rail wir\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 19:55
S15 9	30	filler adj cell same structure and metal and layer	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 19:55
S15 8	2	(multi adj2 layer) same interconnect\$3 same metal and (filler dummy through) adj4 cell and 716/1-18.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 19:54
S15 7	55	(multi adj2 layer) same interconnect\$3 same metal and (filler dummy through) adj4 cell	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 19:34

2/17/2006 2:36:34 PM C:\Documents and Settings\tto2\My Documents\EAST\Workspaces\10_701_249v2.wsp Page 3

S15 6	1885	(multi adj2 layer) same interconnect\$3 same metal	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 19:32
S15 4	24	filler adj cell same layer and metal and (interconnect\$3 connect\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:57
S15 3	27	filler adj cell same layer and metal	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:57
S15 2	50	filler adj cell same layer	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:56
S15 1	30	(non adj2 used) same (through same cell) same (metal layer)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:56
S15 0	1	(non adj used) adj4 (through adj2 cell) same (metal layer)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:54
S14 9	9	S147 and S148	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:22
S14 8	8370	signal adj (line wir\$3) same distan\$2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:05

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S14 7	1662	S146 and S141	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:04
S14 6	33025	(filler feed adj2 through dummy adj cell) same (upper lower) same (layer metal)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:03
S14 0	3145	(filler adj cell feed adj2 through dummy adj cell) same (upper lower) same (layer metal)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:03
S14 5	1	S140 and S141 and signal and via and 716/1-18.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:01
S14 4	73	S140 and S141 and signal and via	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:01
S14 3	137	S140 and S141 and signal	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:01
S14 2	383	S140 and S141	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 18:00
S14 1	327583	(connect\$3 interconnect\$3 inter-connect\$3) same (power ground) same (rail wir\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/16 17:59

S13 1	9	S127 and S128 and S129 and S130	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/15 12:22
S13 0	479964	signal adj3 (line wir\$3 path)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/15 10:57
S12 9	34386	(upper lower) adj4 (layer metal) same (power ground vdd vss supply)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/15 10:55
S12 8	79099	(multi\$3 plurality more) adj4 (layer) same metal	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/15 10:53
S12 7	14942	(filler dummy feed-through) with cell	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/15 10:50

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L5	778	716/11.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/17 17:04
L3	936	716/10.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/17 16:07

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1 HAPPI: a chip compiler based on double-level-metal technology Rathin Putatunda, David Smith, Stephen McNeary, James Crabbe

July 1986 Proceedings of the 23rd ACM/IEEE conference on Design automation

Publisher: IEEE Press

Full text available: 🔁 pdf(853.27 KB) Additional Information: full citation, abstract, references, index terms

This paper describes a unique fully automatic chip compiler, HAPPI, that uses doublelevel-metal technology and 3 levels of interconnection to realize high-speed and maximum-density chip designs consisting of a varying mixture of custom and standardcell macros within a chip topology that guarantees 100% signal and power routing. A heuristic technique for generating placements of "soft macros" that are balanced in both area and connectivity has been presented. A routing approach ...

2 An advanced multichip module (MCM) for high-performance UNIX servers J. U. Knickerbocker, F. L. Pompeo, A. F. Tai, D. L. Thomas, R. D. Weekly, M. G. Nealon, H. C. Hamel, A. Haridass, J. N. Humenik, R. A. Shelleman, S. N. Reddy, K. M. Prettyman, B. V. Fasano, S. K. Ray, T. E. Lombardi, K. C. Marston, P. A. Coico, P. J. Brofman, L. S. Goldmann, D. L. Edwards, J. A. Zitz, S. Iruvanti, S. L. Shinde, H. P. Longworth November 2002 IBM Journal of Research and Development, Volume 46 Issue 6

Publisher: IBM Corp.

Additional Information: full citation, abstract, references, citings

In 2001, IBM delivered to the marketplace a high-performance UNIX®-class eServer based on a four-chip multichip module (MCM) code named Regatta. This MCM supports four POWER4 chips, each with 170 million transistors, which utilize the IBM advanced copper back-end interconnect technology. Each chip is attached to the MCM through 7018 flip-chip solder connections. The MCM, fabricated using the IBM high-performance glassceramic technology, features 1.7 million internal copper vias and high-den ...

3 On Whitespace and Stability in Mixed-Size Placement and Physical Synthesis Saurabh N. Adya, Igor L. Markov, Paul G. Villarrubia November 2003 Proceedings of the 2003 IEEE/ACM international conference on

Computer-aided design Publisher: IEEE Computer Society

Full text available: pdf(1.73 MB)

Additional Information: full citation, abstract, index terms

In the context of physical synthesis, large-scale standard-cell placementalgorithms must facilitate incremental changes to layout, bothlocal and global. In particular, flexible gate sizing, net buffering anddetail placement require a certain amount of unused space in everyregion of the die. The need for "local" whitespace is further emphasizedby temperature and power-density limits. Another requirement, the stability of placement







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> Ismail, M.; Hassan, M.F.; Winnie, T.; Arof, A.K.; Nor, K.M.; Power Engineering Conference, 2003. PECon 2003. Proceedings. National 15-16 Dec. 2003 Page(s):289 - 291 Digital Object Identifier 10.1109/PECON.2003.1437459 AbstractPlus | Full Text: PDF(821 KB) | IEEE CNF

5. Designing lithium ion batteries for high power applications

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IEE CNF	IEE Conference Proceeding		Memory Technology, Design and Testing, 1994., Records of the IEEE Inter on			
IEEE STD	IEEE Standard		8-9 Aug. 1994 Page(s):126 - 129 Digital Object Identifier 10.1109/MTDT.1994.397186			
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			 Design concept for radiation hardening of low power and low voltage Schleifer, H.; Ropp, T.v.d.; Hoffmann, K.; Reczek, W.; Solid-State Circuits, IEEE Journal of Volume 30, Issue 7, July 1995 Page(s):826 - 829 Digital Object Identifier 10.1109/4.391125 AbstractPlus Full Text: PDF(288 KB) IEEE JNL Rights and Permissions 			
			3. A 60-ns 16-Mbit DRAM with a minimized sensing delay caused by bit-l capacitance Chou, S.; Takano, T.; Kita, A.; Ichikawa, F.; Uesugi, M.; Solid-State Circuits, IEEE Journal of Volume 24, Issue 5, Oct 1989 Page(s):1176 - 1183 Digital Object Identifier 10.1109/JSSC.1989.572575			
			AbstractPlus Full Text: PDF(804 KB) IEEE JNL Rights and Permissions			
		0	4. A general-purpose two-dimensional process simulator-OPUS for arbit Nishi, K.; Sakamoto, K.; Kuroda, S.; Ueda, J.; Miyoshi, T.; Ushio, S.; Computer-Aided Design of Integrated Circuits and Systems, IEEE Transac Volume 8, Issue 1, Jan. 1989 Page(s):23 - 32 Digital Object Identifier 10.1109/43.21815			
			AbstractPlus Full Text: PDF(884 KB) IEEE JNL Rights and Permissions			
			5. A 16-Mb CMOS SRAM with a 2.3-µm² single-bit-line memory cell Sasaki, K.; Ueda, K.; Takasugi, K.; Toyoshima, H.; Ishibashi, K.; Yamanak Ohki, N.; Solid-State Circuits, IEEE Journal of Volume 28, Issue 11, Nov. 1993 Page(s):1125 - 1130 Digital Object Identifier 10.1109/4.245592			



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Doumae, S.M.; Ozaki, T.; Kanaya, H.; Yamakawa, K.; Kunishima, I.; Oowaki, Y
Solid-State Circuits, IEEE Journal of

Volume 36, .Issue 11, Nov. 2001 Page(s):1713 - 1720 Digital Object Identifier 10.1109/4.962293

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